



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Mao-Yi CHANG et al. Confirmation No: 1409
Appl. No. : 10/635,489
Filed : August 7, 2003
Title : METHOD FOR TRANSFORMING AN AMORPHOUS
SILICON LAYER INTO A POLYSILICON LAYER

TC/A.U. : 2818
Examiner : D. Vu

Docket No.: CHAN3214/REF
Customer No: 23364

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action of February 18, 2005, in connection with the above-identified application. The period for response to this Official Action has been extended to expire on June 18, 2005 by the filing herewith of a Petition for a One Month Extension of Time and payment of the required fee.

Please amend the application as follows:

Amendments to the claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 4 of this paper.